

Ifw



Please Direct All Correspondence to Customer Number **20995**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

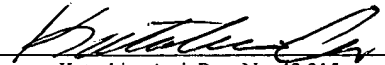
Applicant : HYODO, et al.  
App. No : 10/644,195  
Filed : August 20, 2003  
For : METHOD OF FORMING SILICON-  
CONTAINING INSULATION FILM  
HAVING LOW DIELECTRIC  
CONSTANT AND LOW FILM  
STRESS  
Examiner : Huynh, Yennhu B  
Art Unit : 2813

**CERTIFICATE OF MAILING**

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

September 30, 2005

(Date)

  
Katsuhiro Arai, Reg. No. 43,315

**STATUS LETTER**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Upon review of our records and any available PAIR record, it appears there has been no action in the above-referenced application since Response to Restriction Requirement was filed on February 7, 2005.

Please inform us as to the status of this application.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: September 30, 2005

By: 

Katsuhiro Arai  
Registration No. 43,315  
Attorney of Record  
Customer No. 20,995  
(949) 760-0404